

DECLARATION

I, Shinya HAZUI of Room 401, 4-36, Minatomachi 1-chome, Naniwa-ku, Osaka-shi, Osaka 556-0017 Japan hereby declare that I am conversant with the Japanese language and that I am the translator of the document attached and certify that to the best of my knowledge and belief the following is a true and correct English translation of the specification contained in the Priority Document No. 2003-0099523.

This 30th day of March, 2007

Shinya HAZUI

Thinya Hazai

2003-0099523

(Translation)

[DOCUMENT NAME] Specification

[TITLE OF THE INVENTION] Negative electrode active material and non-aqueous electrolyte rechargeable battery using the same

[CLAIMS]

[Claim 1] A negative electrode active material for a non-aqueous electrolyte rechargeable battery capable of adsorbing/desorbing lithium comprising: an inner layer comprising at least one selected from the group consisting of Si, Sn, an alloy containing Si and an alloy containing Sn; and a surface layer comprising silicon oxide or tin oxide of 0.2 to 1,000 nm in thickness formed on said inner layer.

[Claim 2] The negative electrode active material for a non-aqueous electrolyte rechargeable battery in accordance with claim 1, wherein said alloy comprises Si or Sn, and at least an element selected from the group consisting of Ti, Co, Ni, Cu, Mg, Zr, V, Mo, W, Mn and Fe.

[Claim 3] The negative electrode active material for a non-aqueous electrolyte rechargeable battery in accordance with claim 1, wherein said alloy comprises at least an Si phase or an Sn phase and an alloy phase containing at least an element selected from the group consisting of Ti, Co, Ni, Cu, Mg, Zr, V, Mo, W, Mn and Fe.

[Claim 4] The negative electrode active material for

a non-aqueous electrolyte rechargeable battery in accordance with any one of claims 1 to 3, which is in the form of a thin film or a powder.

[Claim 5] The negative electrode active material for a non-aqueous electrolyte rechargeable battery in accordance with any one of claims 1 to 4 including an amorphous Si phase.

[Claim 6] The negative electrode active material for a non-aqueous electrolyte rechargeable battery comprising the negative electrode active material in accordance with any one of claims 1 to 5.

[DETAILED DESCRITION OF THE INVENTION]
[0001]

[Technical Field to Which the Invention Belongs]

The present invention relates to a negative

electrode active material for a non-aqueous electrolyte

rechargeable battery, and more specifically relates to a nonaqueous electrolyte rechargeable battery having high capacity,

and excellent cycle life characteristic and high-temperature

storage characteristic.

[0002]

[Prior Art]

A lithium rechargeable battery has conventionally been used as a power source for mobile telecommunication equipment and portable electronic equipment. The lithium secondary battery exhibits higher electromotive force and higher energy density than alkaline storage batteries such as

a nickel-cadmium storage battery and a nickel metal-hydride storage battery and utilizes lithium metal or graphite powder as a negative electrode material.

[0003]

However, when the lithium metal is used as the negative electrode material of the lithium rechargeable battery, dendrites are deposited on the negative electrode in a charging state. The dendrites grow through repeated charge and discharge and penetrate a separator, which may possibly cause internal short circuit. Correspondingly, the cycle life may possibly decrease.

On the other hand, when the graphite powder is used as the negative electrode material of the lithium rechargeable battery, the theoretical capacity of the graphite powder (372 mAh/g) is about 10 % of that of elemental lithium metal. Therefore, the graphite powder is disadvantageous in that it cannot meet the growing demand for higher energy density.

Under these circumstances, in recent years, attempts have been made to use other materials having higher theoretical capacity as novel negative electrode materials, e.g., silicon (theoretical capacity: 4199 mAh/g), tin (theoretical capacity: 993 mAh/g) and an alloy containing these elements.

For example, Patent Document 1 discloses a negative electrode material represented by $M_{100-x}\mathrm{Si}_x$ (where M is Ni, Fe,

Co or Mn and x (at%) ≥ 50).
[0005]

Further, the Publication also discloses how to produce the negative electrode material. First, M and Si are weighed to have a predetermined molar ratio (1-x):x and melted by high-frequency induction melting process in atmospheric air to obtain a molten alloy. This molten alloy is quenched by a single roll process or the like for solidification to give an alloy mass of $M_{1-x}Si_x$. Then, the alloy mass is pulverized into a fine powder using a jet mill to obtain an alloy powder as the negative electrode material.

[0006]

[Patent Document 1]

Japanese Laid-Open Patent Publication No. Heil0-

294112

[0007]

[Problem That the Invention Is to Solve]

However, the inventors' analysis has found that the above material is high in capacity but unsatisfactory in cycle life characteristic.

According to a charge/discharge test of a battery similar to that of Example 3 of the Patent Document 1, the initial battery capacity was as high as about 1300 mAh/cc. However, after the 100th charge/discharge cycle, the battery capacity was reduced to 30% of the capacity at the first cycle. Therefore, sufficient cycle life characteristic was not

obtained.

[8000]

A cause of the insufficient cycle life characteristic is considered as follows.

During the preparation of the molten alloy by high-frequency induction melting process in atmospheric air, oxygen becomes mixed therein to form silicon oxide on the alloy surface. Since the resistivity of silicon oxide is as high as $10^{12}~\Omega$ ·m ("Latest Handbook of Oxide", Moscow Metallurgy), Li ions are not smoothly adsorbed to and desorbed from the alloy surface in a charge/discharge reaction. Thereby, the reaction resistance is prone to increase.

[0009]

In fact, the presence of silicon oxide was actually observed on the alloy surface by X-ray photoelectron spectroscopy (XPS). A thickness of silicon oxide was about 1,100 nm, which increased up to about 1,300 nm after the 100th cycle. The precise mechanism of the increase in thickness of silicon oxide through the repeated charge and discharge is unknown. However, due to the presence of silicon oxide having high reaction resistance, a side reaction is prone to occur between oxygen atoms in the electrolyte and the alloy containing silicon, as well as the electrochemical reaction between the alloy and the Li ions. For that reason, it is presumed that silicon oxide increased in thickness through the repeated charge and discharge.

[0010]

[0011]

Therefore, the increase in thickness of this silicon oxide brings about an increase in reaction resistance, which presumably results in the unsatisfactory cycle life characteristic.

According to a close study on this matter, the inventors of the present invention have found it effective at solving the above problem to limit the thickness of silicon oxide formed on the surface of the alloy.

Thus, to solve the conventional problems described above, the present invention intends to provide a negative electrode active material for a non-aqueous electrolyte rechargeable battery which adsorbs a large amount of lithium and has reduced reaction resistance. Further, with the use of the negative electrode active material, the present invention intends to provide a non-aqueous electrolyte rechargeable battery having high capacity, and excellent cycle life characteristic and high-temperature storage characteristic.

[Means for Solving the Problem]

A negative electrode active material for a nonaqueous electrolyte rechargeable battery of the present invention is capable of adsorbing and desorbing lithium and comprises: an inner layer comprising at least one selected from the group consisting of Si, Sn, an alloy containing Si and an alloy containing Sn; and a surface layer comprising silicon oxide or tin oxide of 0.2 to 1,000 nm in thickness formed on the inner layer.

[0013]

The alloy preferably comprises Si or Sn and at least an element selected from the group consisting of Ti, Co, Ni, Cu, Mg, Zr, V, Mo, W, Mn and Fe.

The alloy preferably comprises at least an Si phase or an Sn phase and an alloy phase containing at least an element selected from the group consisting of Ti, Co, Ni, Cu, Mg, Zr, V, Mo, W, Mn and Fe.

[0014]

The negative electrode active material is preferably in the form of a thin film or a powder.

The negative electrode active material preferably includes an amorphous Si phase.

The present invention further relates to a non-aqueous electrolyte rechargeable battery comprising the above-described negative electrode active material.

[0015]

[Mode for Embodying the Invention]

The present invention relates to a negative electrode active material for a non-aqueous electrolyte rechargeable battery capable of adsorbing and desorbing lithium and comprises: an inner layer comprising at least one selected from the group consisting of Si, Sn, an alloy

containing Si and an alloy containing Sn; and a surface layer comprising silicon oxide or tin oxide of 0.2 to 1,000 nm in thickness formed on the inner layer.

If the thickness of said silicon oxide or tin oxide is 1,000 nm or smaller, the reaction resistance becomes low and its increase is inhibited even if the charge and discharge are repeated. Thereby, a favorable cycle life characteristic is obtained.

On the other hand, if the thickness of said silicon oxide or tin oxide is larger than 1,000 nm, the reaction resistance becomes high due to the too-large thickness of silicon oxide or tin oxide. Accordingly, the cycle life characteristic becomes insufficient.

[0017]

[0016]

As a result of a close study on high-temperature storage characteristic as another battery characteristic, it has been found that the high-temperature storage characteristic is favorable when the thickness of silicon oxide or tin oxide is 0.2 nm or larger, but deteriorated when the thickness is less than 0.2 nm. In this context, the favorable high-temperature storage characteristic means that a battery in a charged state exhibits high discharge capacity after being stored at high temperatures.

[0018]

Though the precise mechanism is unknown, it is

assumed that a side reaction between the alloy surface and the electrolyte is prone to occur in a high temperature state, and silicon oxide or tin oxide prevents the side reaction. If silicon oxide or tin oxide is too thin or does not exist, the side reaction cannot be prevented, thereby increasing the reaction resistance, decreasing the discharge capacity and deteriorating the high-temperature storage characteristic.

[0019]

Therefore, the favorable cycle life characteristic and high-temperature storage characteristic are obtained when the thickness of silicon oxide or tin oxide formed on the inner layer comprising at least one selected from the group consisting of Si, Sn, an alloy containing Si and an alloy containing Sn is 0.2 to 1,000 nm.

[0020]

It is preferable that the alloy includes Si or Sn, and at least an element selected from the group consisting of Ti, Co, Ni, Cu, Mg, Zr, V, Mo, W, Mn and Fe. With use of such an alloy, the negative electrode active material can be stabilized and prevented from pulverizing during the repeated charge and discharge. If the negative electrode active material is pulverized, the negative electrode active material decreases in reactivity and the cycle life is apt to decrease. [0021]

Further, if the ratio of the element to be alloyed with Si or Sn increases, the capacity of the resulting alloy

decreases. Therefore, it is not preferable to use the element to be alloyed with Si or Sn in a larger ratio than is necessary.

[0022]

The alloy preferably includes at least an Si phase or an Sn phase, Si or Sn, and an alloy phase containing at least an element selected from the group consisting of Ti, Co, Ni, Cu, Mg, Zr, V, Mo, W, Mn and Fe.

[0023]

The use of such an alloy can prevent the negative electrode active material from pulverizing during the repeated charge and discharge more effectively. Accordingly, further improvement in cycle life characteristic is expected.

[0024]

The above-described negative electrode active material may be in either form of a thin film or a powder.

The thin film may be formed by any method as long as the method forms a thin film. For example, vacuum deposition, chemical vapor deposition (CVD), sputtering, plating and the like may be employed.

[0025]

The powder may be formed by any method as long as the method gives a powder. For example, may be adopted a method of preparing an alloy mass first and then pulverizing the mass into a powder and a method of directly preparing a powder. Examples thereof include a method of preparing an

alloy mass by a melting method and then pulverizing the mass with a stamp mill or ball mill, and a method of directly obtaining a powder by atomization or mechanical alloying.

Other examples of the method for preparing the alloy mass include a roll quenching method and a rotational electrode method.

[0026]

The above-described negative electrode active material preferably includes an amorphous Si phase. The amorphous Si phase is more effective in inhibiting the pulverizing of the negative electrode active material through the repeated charge and discharge than a crystalline Si phase, thereby improving the cycle life characteristic.

In this context, the amorphous Si phase means a phase in which a peak is not at a diffraction angle (2θ) attributed to the crystalline plane of the Si phase in a wide angle X-ray diffraction pattern of Si. On the other hand, the crystalline Si phase means a phase in which a peak is at a diffraction angle (2θ) attributed to the crystalline plane of the Si phase in a wide angle X-ray diffraction pattern of Si. [0027]

[Working Examples]

Hereinafter, the present invention is explained in detail by way of Examples. However, the invention is not limited thereto.

[0028]

⟨Examples 1-12 and Comparative Examples 1-9⟩

(i) Preparation of negative electrode active material

In Examples 1-6 and Comparative Examples 1-4, alloys containing Si or Sn were synthesized in the following manner. Table 1 shows the compositions of the alloys.

First, certain elements in the form of mass, plate or particles were mixed in a given ratio, which was melted under an Ar atmosphere by high-frequency induction melting process. Then, the resulting alloy mass was pulverized with a stamp mill under the Ar atmosphere. The obtained alloy was shifted through a sieve of 45 micron mesh to obtain negative electrode active material particles having an average particle diameter of 28 $\mu \rm m$.

[0029]

The obtained alloy powder was subjected to heat treatment at 200 $^{\circ}$ C for one hour under an atmosphere of oxygen and Ar mixed in a volume ratio of 0.5:99.5 (Examples 1 and 4).

The obtained alloy powder was subjected to heat treatment in the same manner as in Example 1 except that an atmosphere of oxygen and Ar mixed in a volume ratio of 10:90 was used (Examples 2 and 5).

The obtained alloy powder was immersed in an aqueous solution containing 0.5% by weight of hydrofluoric acid at room temperature for 5 minutes and then dried at 60 $^{\circ}$ C under vacuum (Examples 3 and 6).

[0030]

The obtained alloy powder was subjected to heat treatment at 200 $^{\circ}$ for an hour under atmospheric air (Comparative Examples 1 and 3).

The obtained alloy powder was immersed in a mixed aqueous solution containing 20% by weight of hydrofluoric acid and 20% by weight of nitric acid at room temperature for 5 minutes and then dried at 60 $^{\circ}$ under vacuum (Comparative Examples 2 and 4).

[0031]

In Examples 7 to 12 and Comparative Examples 5 to 8, Si or Sn powder was treated in the following manner.

Si or Sn powder was subjected to heat treatment at 200~% for an hour under an atmosphere of oxygen and Ar mixed in a volume ratio of 0.5:99.5 (Examples 7 and 10).

Si or Sn powder was subjected to heat treatment in the same manner as in Example 7 except that an atmosphere of oxygen and Ar mixed in a volume ratio of 10:90 was used (Examples 8 and 11).

Si or Sn powder was immersed in an aqueous solution containing 0.5% by weight of hydrofluoric acid at room temperature for 5 minutes and then dried at 60 $^{\circ}$ C under vacuum (Examples 9 and 12).

[0032]

Si or Sn powder was subjected to heat treatment at 200 $^{\circ}\mathrm{C}$ for 1 hour under atmospheric air (Comparative examples 5 and 7).

Si or Sn powder was immersed in a mixed aqueous . solution containing 20% by weight of hydrofluoric acid and 20% by weight of nitric acid at room temperature for 5 minutes and then dried at 60 $^{\circ}$ C under vacuum (Comparative Examples 6 and 8). [0033]

(ii) Production of negative electrode

Using the negative electrode active materials formed in Examples 1-12 and Comparative Examples 1-8, negative electrodes were formed. Further, a comparative negative electrode was formed using graphite (Comparative Example 9).

Each of the negative electrode active material powders shown in Tables 1 was mixed with a carbon powder as a conductive material and PVdF as a binder in a ratio of 75:20:5 by weight to give a mixture. The mixture was dispersed in dehydrated N-methylpyrrolidinone to obtain a slurry. This slurry was applied to an electrolytic copper foil serving as a negative electrode current collector, which was dried and then rolled to give a negative electrode.

[0034]

(iii) Production of positive electrode

Lithium cobaltate (LiCoO₂) powder as a positive electrode active material, a carbon powder as a conductive material and PVdF as a binder were mixed in a ratio of 85:10:5 by weight to give a mixture. This mixture was dispersed in dehydrated N-methylpyrrolidinone to give a slurry. This slurry was applied to an aluminum foil serving as a positive

electrode current collector, which was dried and then rolled to give a positive electrode.

[0035]

(iv) Fabrication of non-aqueous electrolyte rechargeable battery

FIG. 1 is a schematic vertical section of a non-aqueous electrolyte rechargeable battery. The non-aqueous electrolyte rechargeable battery as shown in FIG. 1 was fabricated in the following manner.

[0036]

A positive electrode 5 and a negative electrode 6, which were obtained as described above, were stacked with a separator 7 interposed therebetween and rolled up to form an electrode assembly 4. Insulating rings 8 were attached to the top and the bottom of the electrode assembly 4, respectively. The positive electrode 5 was connected to a sealing plate 2 via a positive electrode lead 5a. The negative electrode 6 was connected to the bottom of a battery case (negative electrode can) 1 via a negative electrode lead 6a. Then, the electrode assembly 4 was placed in the battery case 1, in which a non-aqueous electrolyte was poured. The non-aqueous electrolyte used was a solvent mixture of ethylene carbonate and ethyl methyl carbonate in a volume ratio of 1:1 containing 1 mol/L of LiPF₆.

[0037]

Then, the battery case 1 was sealed with the sealing

plate 2 provided with an insulating packing 3. In this manner, batteries A1-A12 (using the negative electrode active materials of Examples 1-12) and batteries X1-X9 (using the negative electrode active materials of Comparative Example 1-9) were fabricated, each of which was a cylindrical sealed lithium rechargeable battery of 18 mm in diameter and 65 mm in height. The non-aqueous electrolyte rechargeable batteries were fabricated under a dry air atmosphere adjusted to have a dew point of -50~% or lower.

[0038]

[Evaluations]

① Cycle life test

Each of the batteries was subjected to repeated charge/discharge cycles. The charge was performed at 0.6 A up to 4.2 V at 20 $^{\circ}$ C and then the discharge was performed at 0.4 A down to 2.5 V at 20 $^{\circ}$ C. At that time, discharge capacity C1 at the first cycle and discharge capacity C2 at the 100^{th} cycle were measured. With respect to every battery, the ratio P (%) of discharge capacity C2 to discharge capacity C1 was calculated from the formula shown below to evaluate the cycle life characteristic of the battery. The cycle life characteristic was judged as satisfactory when the value P was 85 % or higher.

$$P (%) = (C2/C1) \times 100$$

[0039]

② Qualitative analysis and thickness measurement of silicon

oxide

Qualitative analysis of silicon oxide was conducted using XPS-7000 manufactured by Rigaku Corporation. Al-K α was used as an X-ray source. Narrow scan measurement was conducted under the conditions of a voltage of 10 kV, a current of 10 mA, an energy range of 114 to 94 eV and a step size of 0.08 eV. Si2p was used as the measurement element. [0040]

Further, the thickness of silicon oxide was measured in the following manner.

Silicon oxide was subjected to Ar ion etching. The thickness of silicon oxide was determined as the difference between the etch depth when a peak of silicon oxide began to appear and the etch depth when the peak disappeared. The etching was performed under the conditions of accelerated voltage of 500 V, etching angle of 90° , ion current density of $160~\mu\text{A/cm}^2$ and the etching rate of 0.5-5 nm/minute in terms of SiO_2 . The minimum etch depth was 0.2 nm.

3 Measurement of internal resistance of battery

Internal resistance of the battery at a frequency of 1 kHz was measured by an A/C impedance method. The measurement was performed after discharge at the first cycle and the $100^{\rm th}$ cycle of the above-described charge/discharge cycles.

[0042]

4 High-temperature storage test

After 5 charge/discharge cycles performed in the above-mentioned manner, discharge capacity C3 at the 5th cycle was measured. Then, after the 6th cycle charge, the battery was stored in a chamber at 80 $^{\circ}$ C for 3 days. After the storage period, the battery was discharged at 0.4 A down to 2.5 V at 20 $^{\circ}$ C to obtain discharge capacity C4. The ratio Q (%) of discharge capacity C4 to discharge capacity C3 at the 5th cycle was calculated by the following formula to evaluate the high-temperature storage characteristic of the battery. The high-temperature storage characteristic was judged as satisfactory when the value Q was 85 % or higher.

$$Q(\$) = (C4/C3) \times 100$$

Table 1 shows the evaluation results of each test.
[0043]

[Table 1]

<u></u>					J			I	1			1		γ	-	Ţ		\neg		Ţ				
esistance	Q)	100 th	cycle	43	47	40	44	48	41	45	49	42	46	20	43	125	40	127	42	130	41	131	42	43
Battery resistance	(mQ)	First	cycle	40	43	36	41	44	3.7	42	45	38	43	46	39	80	35	82	37	85	37	86	38	40
	Ratio	(%)0		89.7	92.0	87.3	89.5	91.8	87.1	86.1	86.9	85.1	85.8	86.7	85.0	92.3	53.6	92.1	53.3	88.1	49.5	87.8	48.9	90.3
	DischargeDischarge	capacity	(IIII)	2487	2526	2432	2472	2511	2417	2500	2510	2486	2485	2495	2475	2440	1500	2425	1485	2477	1453	2466	1429	1800
	Discharge		C3 (IIIAII)	2773	2746	2786	2762	2736	2776	2905	2889	2921	2895	2879	2911	2642	2799	2632	2789	2813	2933	2808	2923	1994
	Datio			94.7	93.5	95.1	94.5	93.3	94.9	85.7	85.5	0.98	85.5	85.3	85.8	49.4	92.6	49.1	95.4	43.2	88.6	43.0	88.5	93.5
	Discharge	capacity	CZ (mAn)	2634	2576	2655	2619	2561	2640	2508	2488	2530	2493	2473	2515	1340	2682	1325	2667	1251	2614	1243	2603	1870
	DischargeDischarge	~	C1(mAn)	2780	2755	2793	2770	2745	2783	2926	2910	2942	2916	2900	2932	2711	2805	2701	2795	2895	2950	2890	2940	2000
Thickness	of		or tin oxide(nm)	100	1000	0.2	100	1000	0.2	100	1000	0.2	100	1000	0.2	1100	<0.2	1100	<0.2	1100	<0.2	1100	<0.2	1
		number Composition		TiSi3	TiSi3	TiSi3	Ti2Sn3	Ti ₂ Sn ₃	Ti ₂ Sn ₃	Si	Si	Si	Sn	Sn	Sn	TiSi3	TiSi3	Ti ₂ Sn ₃	Ti,Sn3	Si	Si	Sn	Sn	Graphite
	4	number		A1	A2	A3	A4	A5	A6	A7	A8	A9	A10	A11	A12	X1	X2	Х3	X4	X5	9X			6X
		•		Ex. 1	Ex. 2	Ex. 3	Ex. 4	Ex. 5	Ex. 6	Ex. 7	Ex. 8	Ex. 9	Ex. 10	Ex. 11	Ex. 12	Com.Ex. 1	Com.Ex. 2	Com.Ex. 3	Com.Ex. 4	Com.Ex. 5	Com.Ex. 6	Com.Ex. 7	Com.Ex. 8	Com.Ex. 9

[0044]

As Table 1 shows, the batteries A1-A12 using the negative electrode active materials of Examples 1-12 showed higher capacity than that of the battery X9 of Comparative Example 9. Further, the cycle life characteristic and the high-temperature storage characteristic of the batteries A1-A12 were as excellent as those of the battery X9.

The thickness of silicon oxide or tin oxide on the surface of the alloy powder as the negative electrode active material was 100 nm in Examples 1, 4, 7 and 10, 1,000 nm in Examples 2, 5, 8 and 11 and 0.2 nm in Examples 3, 6, 9 and 12. [0045]

The batteries A1-A12 using these negative electrode active materials showed the ratio P of 85.3-95.1 %, indicating that these batteries were favorable in cycle life characteristic. Further, the ratio Q was 85.0-92.0 %, showing that these batteries were excellent in high-temperature storage characteristic.

[0046]

The batteries A1-A12 showed the battery resistance of 36-46 m Ω at the first cycle, which was not so high. After the 100^{th} cycle, the increase of the battery resistance was as small as 3-4 m Ω . Accordingly, it was found that the initial reaction resistance was low when the average thickness of silicon oxide or tin oxide was 1,000 nm or smaller and the reaction resistance was prevented from increasing through the

repeated charge and discharge. Thus, satisfactory cycle life characteristic was given.

[0047]

On the other hand, in Comparative Example 1, the thickness of silicon oxide on the alloy powder surface was 1,100 nm. Further, the battery resistance at the first cycle of the battery X1 of Comparative Example 1 was 80 m Ω , which was higher than that of the batteries A1-A12 of Examples 1-12. After the 100^{th} cycle, the battery resistance was 125 m Ω , which was higher than the initial battery resistance by 45 m Ω . [0048]

In view of these results, it was proved that the thickness of silicon oxide larger than 1,000 nm increases the reaction resistance due to the too-large thickness, thereby increasing the battery resistance. In consequence, the ratio P was 49.4 %, leading to unsatisfactory cycle life characteristic. The batteries X3, X5 and X7 of Comparative Example 3, 5 and 7 also showed insufficient cycle life characteristic for the same reason applied to the battery X1 of Comparative Example 1.

[0049]

Regarding the battery X2 of Comparative Example 2, silicon oxide on the alloy surface was not quantitative analyzed at the etch depth of 0.2 nm, and was not quantitative analyzed at the greater depth. Therefore, the thickness of silicon oxide on the alloy surface was estimated as less than

0.2 nm or does not exist at all. Thus, the reaction resistance derived from silicon oxide was almost zero and the ratio P was 95.6%, indicating that the cycle life characteristic was excellent. However, the ratio Q was 53.6%, showing that the high-temperature storage characteristic was unsatisfactory.

[0050]

Though the precise mechanism is unknown, it is assumed that silicon oxide or tin oxide inhibits a side reaction between the alloy surface and the electrolyte, which occurs vigorously in a high temperature state. Therefore, if silicon oxide or tin oxide is too thin or does not exist, the side reaction cannot be inhibited. Accordingly, the reaction resistance increases, discharge capacity is apt to decrease and the high-temperature storage characteristic is impaired. The batteries X4, X6 and X8 of Comparative Examples 4, 6 and 8 showed unsatisfactory high-temperature storage characteristic for the same reason applied to the battery of Comparative Example 2.

[0051]

《Examples 13-34》

Alloys shown in Table 2 were prepared by combining Si and at least an element selected from the group consisting of Co, Ni, Cu, Mg, Zr, V, Mo, W, Mn and Fe in the same manner as in Example 1 (Examples 13-23). Further, alloys shown in Table 2 were prepared by combining Sn and at least an element

selected from the group consisting of Co, Ni, Cu, Mg, Zr, V, Mo, W, Mn and Fe (Examples 24-34).
[0052]

Negative electrodes were prepared in the same manner as in Example 1 except that the above obtained alloy powders were used as the negative electrode active materials, respectively. Then, batteries A13-A34 were fabricated in the same manner as in Example 1 except that these negative electrodes were used.

The batteries A13-A34 were evaluated in the same manner as the battery A1 of Example 1. Table 2 shows the evaluation results.

[0053]

2]

[Table

100th cycle 44 45 44 44 44 46 46 45 45 44 45 45 46 45 45 47 resistance Battery (MD) cycle First 41 42 41 42 42 42 41 42 42 43 42 42 44 41 41 Thickness Discharge Discharge Ratio Discharge Discharge Ratio 89.0 89.3 89.5 89.4 89.5 89.4 89.2 89.2 89.3 89.2 9.68 89.3 89.2 88.8 89.2 89.3 89.2 0(%) P(%) capacity capacity C4 (mAh) 2480 2475 2470 2455 2472 2470 2470 2469 2468 2465 2465 2455 2440 2449 2455 2461 2457 C3 (mAh) 2772 2763 2762 2762 2769 2768 2764 2764 2764 2753 2762 2747 2752 2757 2747 2752 2757 93.8 94.0 94.2 93.5 93.6 93.7 93.9 93.8 94.0 93.8 93.4 94.1 94.2 94.1 94.0 94.2 94.1 capacity capacity C1(mAh) 2615 2609 2595 2600 2609 2590 2603 2600 2608 2605 2599 2585 2590 2599 2601 2602 2580 2780 2766 2765 2770 2778 2777 2772 2773 2772 2770 2755 2755 2760 2771 2771 2761 2761 of silicon oxide (nm) or tin 100 100 100 100 100 100 100 100 100 100 100 100 100 100 100 100 100 Battery Composition Coo.sNio.sSi3 Cu_2Sn_3 $FeSi_3$ $NiSn_3$ NiSi3 $ZrSn_3$ $CoSi_3$ $ZrSi_3$ $MoSi_3$ $MnSi_3$ $CoSn_3$ MgSn CuSi MgSi VSi_3 $WS1_3$ VSn_3 number A15 A16 A18 A19 A20 A28 A29 A17 A21 A22 A23 A24 A25 A26 A27 16 22 23 24 21 Ex. Ex. Ex. Ex. EX Ex. Ex. EX. Ex. Ex. Ex. EX. Ex. Ex.

46 46 45

42

2754

2598

2762

100

Coo.sNio.sSn3

FeSn₃

33

34

WSn₃

A32 A33 A34

A31

31

EX.

47

44

88.9 88.9 89.0 89.3

2454

2759

93.6

2591 2592 2593 2590

2768

100

MoSn₃

A30

30

EX.

2767 2762 2763

100

100

2453

2758

93.7

2455 2450 2460

2754 2754

93.9

93.7

[0054]

As Table 2 shows, the batteries Al3-A34 showed higher capacity than the battery X9 of Comparative Example 9. Further, the cycle life characteristic and the high-temperature storage characteristic of the batteries Al3-A34 were as excellent as those of the battery X9.

As Table 2 shows, the batteries A13-A34 showed the ratio P of 93.4-94.2 %, indicating that these batteries were satisfactory in cycle life characteristic. Further, the ratio Q was 88.8-89.6 %, showing that these batteries were excellent in high-temperature storage characteristic. In these batteries, the thickness of silicon oxide or tin oxide on the alloy powder surface was 0.2-1,000 nm.

≪Examples 35-38≫

[0055]

Alloys having the compositions shown in Table 3 were prepared in the following manner.

First, certain elements in the form of mass, plate or particles were mixed in a given ratio, which was melted under an Ar atmosphere by high-frequency induction melting process. Then, the mixture was cooled under the Ar atmosphere by atomization to prepare spherical alloy powder as a negative electrode active material. The alloy powder was shifted through a sieve of 45 micron mesh to give alloy powders having an average particle diameter of 28 μ m. These alloy powders were subjected to heat treatment under the same conditions as

in Example 1.

[0056]

According to measurement by wide angle X-ray diffraction of the resulting alloy powders, the alloy powder of Example 35 included two phases of an Si phase and a $TiSi_2$ phase, while that of Example 36 included two phases of an Sn phase and a Ti_6Sn_5 phase.

[0057]

Each negative electrode was prepared in the same manner as in Example 1 except that the alloy powders thus obtained were used as the negative electrode active material.

Batteries A35-A38 were fabricated in the same manner as in Example 1 except that the obtained negative electrode was used.

The batteries were evaluated in the same manner as the battery Al of Example 1.

Table 3 shows the evaluation results.

[0058]

[Table 3]

	Battery	Battery number	Alloy phase	Thickness of silicon capacity capacity oxide(nm)	Discharge capacity C1(mAh)	Discharge capacity C2(mAh)	Ratio P(%)	Discharge capacity C3(mAh)	Discharge capacity C4(mAh)	Ratio Q(%)	$\begin{array}{c} {\tt Battery} \\ {\tt resistance} \\ {\tt (m\Omega)} \\ {\tt First} \boxed{100^{\tt th}} \end{array}$	tance
_											cycle cycle	cycle
!	Ex. 35 A35	\mathtt{TiSi}_3	TiSi ₃ Si+TiSi ₂	100	2780	2655	95.5	2655 95.5 2774	2488 89.7 40 43	89.7	40	43
	Ex. 36 A36	Ti ₂ Sn ₃ Sn+Ti ₆ Sn ₅	Sn+Ti ₆ Sn ₅	100	2770	2643	95.4	2643 95.4 2764	2473 89.5 41	89.5	41	44
	Ex. 37 A37	\mathtt{TiSi}_2	$TiSi_2$	100	2605	2381	91.4	2381 91.4 2594	2325 89.6 40 43	89.6	40	43
	Ex. 38 A38	Ti.Sn. Ti.Sn.	1	100	2600	2377	91.4	2377 91 4 2589	2319 89 6 41 44	89 6	41	44

[0059]

As Table 3 shows, the batteries A37 and A38 each using the single-phase alloys of Examples 37 and 38 as the negative electrode active materials showed excellent cycle life characteristic and high-temperature storage characteristic. The batteries A35 and A36 each using the two-phase alloys of Examples 35 and 36 as the negative electrode active materials showed superior cycle life characteristic and high-temperature storage characteristic to those of the batteries A37 and A38.

[0060]

≪Examples 39-45≫

According to various methods as described below, thin Si films were formed.

According to vacuum deposition, an Si mass was evaporated using an electron beam under vacuum of about 0.00003 Torr to form a thin Si film on an electrolytic copper foil (Example 39).

[0061]

According to chemical vapor deposition (CVD), silane was used as a source gas and hydrogen was used as a carrier gas. Then, a thin Si film was formed on an electrolytic copper foil under vacuum of 0.3 Torr while heating the electrolytic copper foil at 200 $^{\circ}$ (Example 40). [0062]

Further, a thin Si film was formed by sputtering on

an electrolytic copper foil under vacuum of 0.1 Torr and high frequency power of 200 W (Example 41).

The thus obtained thin Si films were subjected to heat treatment under an atmosphere of oxygen and Ar mixed in the volume ratio of 0.5:99.5 at 200~% for an hour. [0063]

Further, a thin $TiSi_2$ alloy film was formed by vacuum deposition as described below (Example 43).

Masses of Si and Ti were evaporated under vacuum of about 0.00003 Torr using an electron beam to form a thin $TiSi_2$ alloy film on an electrolytic copper foil. The thin $TiSi_2$ alloy film was subjected to heat treatment under an atmosphere of oxygen and Ar mixed in the volume ratio of 0.5:99.5 at 200 $^{\circ}$ C for an hour.

[0064]

A thin Sn film was formed by electroless plating as described below (Example 42).

A plating solution was prepared by dissolving 0.1 mol/L of SnSO₄ in a 0.1 mol/L H_2SO_4 aqueous solution. In 100 ml of the plating solution, an electrolytic copper foil was immersed at a bath temperature of 40 $^{\circ}$ C for 15 minutes to form a thin Sn film thereon.

Then, the thin Sn film was subjected to heat treatment under an atmosphere of oxygen and Ar mixed in the volume ratio of 0.5:99.5 at 200~% for an hour. [0065]

A thin CoSn alloy film was formed by electroless plating as described below (Example 44).

A plating solution was prepared by dissolving 0.1 mol/L of SnSO₄ and 0.1 mol/L of CoSO₄ in a 0.1 mol/L $\rm H_2SO_4$ aqueous solution. In 100 ml of the plating solution, an electrolytic copper foil was immersed at a bath temperature of 40 $^{\circ}$ C for 15 minutes.

Then, the thin alloy film was subjected to heat treatment under an atmosphere of oxygen and Ar mixed in the volume ratio of 0.5:99.5 at 200~% for an hour. [0066]

A thin film comprising a crystalline Si phase was formed in the following manner (Example 45).

A thin Si film was formed in the same manner as in Example 40, which was subjected to heat treatment under an atmosphere of oxygen and Ar mixed in the volume ratio of 0.5:99.5 at 700 °C for an hour. The thin Si film had a peak at a diffraction angle attributed to Si in a wide angle X-ray diffraction pattern of Si. Therefore, it was confirmed that the thin film comprises the crystalline Si. [0067]

Each of the negative electrode active materials in the thin film form obtained in the above were used as the negative electrodes. Batteries A39-A45 were fabricated in the same manner as in Example 1 except that the thus obtained negative electrodes were used.

The batteries were evaluated in the same manner as the battery Al of Example 1.

Table 4 shows the evaluation results.

[0068]

[Table 4]

0 6 0) [1	_	Т	_	Τ	т-
Battery resistance (mQ)	45	45	45	46	43	44	45
Battery resistance (m\O) First 100 th	88.6 42	42	42	43	40	41	42
Ratio Q(%)	88.6	88.3	88.6	85.6	9.68	89.9	87.5
Discharge Discharge Ratio capacity capacity C2(mAh) C2(mAh)	2585	2578	2590	2506	2321	2192	2545
Discharge capacity C3(mAh)	2917	2919	2922	2929	2590	2438	2910
Ratio P(%)	91.1	91.0	91.0	85.5	91.9	90.4	86.3
Discharge Ratio C2(mAh)	2670	2667	2672	2521	2390	2214	2530
Discharge capacity C1(mAh)	2930	2932	2935	2950	2600	2450	2930
Thickness of silicon or tin oxide(nm)	100	100	100	100	100	100	100
Battery Composition of sil	Si	Si	Si	Sn	\mathtt{TiSi}_2	CoSn	Si
Battery	A39	A40	A41	A42	A43	A44	A45
-	Ex. 39	Ex. 40	Ex. 41	Ex. 42	Ex. 43	44	Ex. 45
	ایرا	×.	<u>.</u>	<u>.</u>	×	EX.	.

[0069]

As Table 4 shows, the batteries A39-A45 of Examples 39-45 showed higher capacity than the battery X9 of Comparative Example 9. Further, the cycle life characteristic and the high-temperature storage characteristic of the batteries A39-A45 were as excellent as those of the battery X9.

As Table 4 shows, the batteries A39-A45 showed the ratio P of 85.5-91.9 %, indicating that these batteries were satisfactory in cycle life characteristic. Further, the ratio Q was 85.6-89.9 %, showing that these batteries were satisfactory in high-temperature storage characteristic.

[0070]

According to wide angle X-ray diffraction
measurement, the thin Si film of Example 40 had no peak at the
diffraction angle attributed to Si and was found to comprise
an amorphous Si phase. In comparison with the thin film of
Example 45 comprising a crystalline Si phase, the battery A40
of Example 40 showed the ratio P of 91.0 %, which was higher
than the ratio P of the battery A45 (86.3 %) as shown in Table
4, indicating that excellent cycle life characteristic was
obtained.

It is assumed that the amorphous Si phase is more effective than the crystalline Si phase in inhibiting the pulverization of the negative electrode active material during the repeated charge and discharge.

[0071]

In the above Examples, the electrolytic copper foil was used as the copper foil. However, the present invention is not limited thereto. For example, a rolled copper foil may be used. The copper foil surface may be flat or rough.

Moreover, $LiCoO_2$ used as the positive electrode active material in Examples of the present invention may be replaced with a positive electrode capable of reversibly charging and discharging, such as $LiMn_2O_4$ and $LiNiO_2$.

[0072]

Further, the above Examples were applied to a cylindrical battery. However, the present invention is not limited to this structure and has a similar effect when it is applied to rechargeable batteries in a coin form, prismatic form and flat form.

[0073]

[Effect of the Invention]

As described above, the present invention intends to provide a negative electrode active material for a non-aqueous electrolyte rechargeable battery which adsorbs a large amount of lithium and has reduced reaction resistance. Further, with the use of the negative electrode active material, the present invention intends to provide a non-aqueous electrolyte rechargeable battery having high capacity, and excellent cycle life characteristic and high-temperature storage characteristic.

[BRIEF EXPLANATION OF THE DRAWINGS]

[FIG.1]

A schematic vertical cross section of the cylindrical battery according to Examples of the present invention.

[Explanation of Reference Numerals]

- 1. Battery case
- 2. Sealing plate
- 3. Insulating packing
- 4. Electrode assembly
- 5. Positive electrode
- 6. Negative electrode
- 7. Separator
- 5a Positive lead plate
- 6a Negative lead plate
- 8. Insulating ring



[DOCUMENT NAME] Drawing

[FIG. 1]



2003-099523

(Translation)

[DOCUMENT NAME] Abstract

[ABSTRACT]

[OBJECTIVE] To provide a non-aqueous electrolyte rechargeable battery which adsorbs a large amount of lithium and has reduced reaction resistance.

[SOLVING MEANS] The negative electrode active material for a non-aqueous electrolyte rechargeable battery capable of adsorbing and desorbing lithium includes a inner layer comprising at least one selected from the group consisting of Si, Sn, an alloy containing Si and an alloy containing Sn, and includes a surface layer comprising silicon oxide or tin oxide formed on the inner layer and has a thickness of 0.2 to 1000 nm.

[SELECTED DRAWING] None